I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents and Trademarks, Washington, D.C. 20231, on November 18, 2003. The applicant and/or attorney requests the date of deposit as the filing date. Depositor: Karen Cinq-Mars

The date 1 18/03

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

November 18, 2003

Chidambarrao, Dureseti, et al.:

Group Art Unit: To Be Assigned

Serial No. 10/605,135:

Examiner: To Be Assigned

Filed: 9/10/03

**International Business Machines Corporation** 

2070 Route 52

Hopewell Junction, NY 12533

TITLE: METHOD AND STRUCTURE FOR IMPROVED MOSFET'S USING POLY / SILICIDE GATE HEIGHT CONTROL

## <u>Under 37 C.F.R. 1.56</u>

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Under provisions of 37 C.F.R. 1.97 through 1.99 and pursuant to applicant's duty of disclosure under 37 C.F.R. 1.56, applicants respectfully bring the documents listed on the attached Form PTO-1449 to the attention of the examiner in charge of the above-identified application.

This citation does not constitute an admission that the cited references are relevant or material to the claims nor should it be construed as a representation that no other art than that identified exists. They are merely cited as constituting related art of which the applicant is aware.

It is respectfully requested that these documents be considered by the examiner and formally made of record in this application.

No fee is believed to be due for this submission. If any fees are required, however, the Commissioner is hereby authorized to charge such fees to Deposit Account No. 09-0458.

Respectfully submitted, Dureseti Chidambarrao, et al.

Joseph P. Asate

Registration No 30,238

Telephone No.)845-894-4633

FORM PTO-1449 (Modified) ATTY. DOCKET NO. SERIAL NO. FIS9-2003-0184-US1 10/605,135 LIST OF PATENTS AND PUBLICATIONS OR APPLICANT: APPLICANT'S INFORMATION DISCLOSURE Chidambarrao, Dureseti, et al. **STATEMENT** NOV, 2 0 2003 (Use several sheets if necessary) **GROUP:** FILING DATE: 9/10/03 Unassigned PANDEM DEL REFERENCE DESIGNATION **U.S. PATENT DOCUMENTS EXAMINER DOCUMENT** FILING DATE **INITIALS NUMBER DATE NAME CLASS SUBCLASS** (IF APPRO.) US 6,228,694 B1 5/8/2001 Doyle et al. US 6,406,973 B1 6/18/2002 Lee US 6,281,532 B1 8/28/2001 Doyle et al. 11/4/97 5,683,934 Candelaria US 6,368,931 B1 4/9/2002 Kuhn, et al. 5,310,446 5/10/94 Konishi et al. 4,853,076 8/1/89 Tsaur et al. US 2002/0090791 A1 7/11/2002 Doyle et al. US 2002/0074598 A1 6/20/2002 Doyle et al. 1/21/2003 US 6,509,618 B2 Jan et al. US 6,476,462 B2 11/5/2002 Shimizu et al. US 6,362,082 B1 3/26/2002 Doyle et al. US 6,228,694 B1 5/8/2001 Doyle et al.

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Patent and Trademark Office \* U.S. DEPARTMENT OF COMMERCE

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